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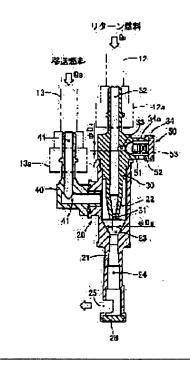
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(54) JET PUMP

(57)Abstract:

PROBLEM TO BE SOLVED: To suppress a flow rate change of liquid, preventing a rise of back pressure by liquid by setting a relief restriction diameter of a relief port within a specified range in a jet pump provided with a relief valve for discharging liquid introduced into an introduction port through the relief port.

SOLUTION: This jet pump 20 discharges introduced liquid from a relief port 33 by a relief valve 50 when pressure within an introduction port 32 becomes a fixed value or more. In this case, when a nozzle restriction diameter of a nozzle 31, a relief restriction diameter of the relief port 33 and the total restriction diameters are fixed as ϕDN, ϕDR and ϕDr, respectively, the relief restriction diameter ϕDR is set within a range of a value determined based on the nozzle restriction diameter ϕDN fixed according to flow rate performance and a minimum value of the total restriction diameter ϕDr capable of discharging maximum flow rate of introduced liquid or more and a value that transfer fluid of prescribed flow rate can be transferred by introduced liquid of minimum flow rate in cased of the relief valve 50 trouble in opening or below.



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